



# IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. .... 10/678,513  
Filing Date ..... October 3, 2003  
Inventor ..... Werner Juengling  
Assignee ..... Micron Technology, Inc.  
Group Art Unit ..... 2812  
Examiner ..... B. Kebede  
Attorney's Docket No. .... MI22-2391  
Customer No. .... 021567

Title: Semiconductor Processing Methods of Forming a Contact Opening to a Conductive Line and Methods of Forming Substrate Active Area Source/Drain Regions

## SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

The attached Form PTO-1449 is submitted in compliance with 37 C.F.R. §§ 1.56, 1.97 and 1.98, your attention is directed to the references listed on the attached Form PTO-1449. Pursuant to Federal Register Vol. 69, No. 182, pg. 56542 (September 21, 2004), no copies of any cited U.S. patents or U.S. published applications are included herewith. Copies of all other cited art references, if any, are attached. No admission is made regarding whether the submitted references are prior art.

Citation of this reference is respectfully requested.

Respectfully submitted,

Dated: 4-10-06

By:

  
D. Brent Kenady  
Reg. No. 40,045

Form PTO-1449

U.S. DEPARTMENT OF COMMERCE  
PATENT AND TRADEMARK OFFICEATTY. DOCKET NO.  
MI22-2391SERIAL NO.  
10/678,513LIST OF ART CITED BY APPLICANT  
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APPLICANT  
Werner JuenglingFILING DATE  
October 3, 2003GROUP  
2823

## U.S. PATENT DOCUMENTS

*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
	AA	6,027,971	02/00	Cho, et al	438	257	
	AB	5,488,001	01/96	Brotherton	999	021	
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
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	AK						
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## FOREIGN PATENT DOCUMENTS

		Document Number	Date	Country	Class	Subclass	Translation	
							Yes	No
	AM							
	AN							
	AO							
	AP							
	AQ							

## OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)

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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.